







Transient simulation of monolithic small collection electrode CMOS sensors in Allpix Squared

Katharina Dort

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2nd Allpix Squared User Workshop



Outline

The sensor design

Transient simulation setup

Comparison to transient 3D TCAD

Comparison to test-beam data

Summary/Outlook





The sensor design



Monolithic silicon sensors

- Small material budget
- Reducing production costs/effort
- Large-scale production possibilities

Small collection electrode design

- Femto-Farad sensor capacitance
- Improving signal-to-noise ratio
- Reducing detection threshold
- Reducing power consumption

- On-chip CMOS electronics shielded by p-well in the active sensor volume
- P-well influences electric field and charge collection behaviour



The sensor design

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 Modified 180 nm CMOS imaging process (e.g. ALPIDE, (Mini-)MALTA, CLICTD,...)

Adding deep low-dose n-implant

• Full lateral depletion of the epitaxial layer

Segmented deep low-dose n-implant

- Lateral doping gradient -> stronger lateral electric field
- Accelerated charge collection
- Reduced charge sharing
- Improved time resolution
- Higher radiation tolerance



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JINST 14 (2019) C05013

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- Complex non-linear field configurations
- due to small collection electrode design
- Knowledge from planar sensors cannot be transferred
- Precise sensor modelling needed
- Field maps from electrostatic 3D TCAD simulations are imported into Allpix Squared





Border of depletion region

30 um



Simulation set-up







Reading field maps from 3D TCAD



- Maps computed with 3D TCAD are converted from an adaptive mesh to a regularly spaced mesh using the Mesh Converter tool
- They are imported using their respective Reader module

Doping profile

- Calculation of charge carrier lifetime
- Calculation of charge carrier mobility

Weighting potential

• Used to compute transient pulse

Electric field

• Used to compute drift of charge carriers in the sensor

```
[DopingProfileReader]
model = "mesh"
file_name = "inputDopingFile.init"
field_offset = 0.5 0.5
```

```
[WeightingPotentialReader]
model = "mesh"
file_name = "inputWeightingPotential.init"
```

```
[ElectricFieldReader]
model = "init"
file_name = "inputElectricFieldFile.init"
depletion_depth = 30um
field offset = 0.5 0.5
```

Transient propagation



- Propagation taking drift and diffusion into account using the combined Masetti-Canali mobility model
- Charge carrier recombination based on the combined Auger and Shockley-Read-Hall model

```
[TransientPropagation]
temperature = 293K
charge_per_step = 10
timestep = 0.0008ns
integration_time = 50ns
induction_matrix = 1,1
recombination_model = "srh_auger"
mobility_model = "masetti_canali"
```

```
[PulseTransfer]
output_plots = false
output_pulsegraphs = false
```

- Induced charge on collection electrode is calculated using the Shockley-Ramo theorem
- The resulting transient pulses are used in the subsequent modules



Comparison to transient 3D TCAD



- Charge injection along straight line at pixel corner (largest distance to electrode -> slowest charge collection expected)
- The transient pulse resembles the output obtained from transient 3D TCAD computations for all investigated pixel flavours



Comparison to test-beam data



The CLICTD technology demonstrator

 Fully integrated monolithic pixel sensor fabricated in modified 180 nm CMOS imaging process IEEE Tran. Nucl. Sci., August 2020 doi: 10.1109/TNS.2020.3019887

Test-beam at the DESY II Test Beam Facility

- 5.4 GeV electron beam
- MIMOSA-26 reference telescope equipped with TimePix3 plane for improved time reference

NIM A 1006 (2021) 0168-9002





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The measurements leading to these results have been performed at the Test Beam Facility at DESY Hamburg (Germany), a member of the Helmholtz Association (HGF)



- Doping profiles are only known to a certain degree
- Introduces systematic uncertainties in the simulations (both 3D TCAD and Allpix Squared)
- Out-diffusion of three different implants was varied by a factor of 3 to quantify impact on cluster observables



Systematic uncertainties

#

- In the following: only modified pixel flavour
- Non-linear impact on cluster size
- Sensor design needs to be optimised such that small variations in the doping profiles do not alter sensor performance significantly



 Transition region

 0.8

 Simulation - High smearing

 Simulation - Low smearing

 Simulation - Nominal

 0.6

 0.4

 0.2

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progress

R&D

EΡ



Spatial resolution



- Band on data represents systematic uncertainties related to threshold calibration and test-beam reconstruction
- Band on simulation represents systematic uncertainties related to the doping profiles
- Simulation with linear electric field does not reproduce the data
- Good agreement using 3D TCAD combined with Allpix Squared



High-resistivity Czochralski material





• High-resistivity Czochralski sample enables combination of small collection electrode with large depleted volume

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- Doping concentration of Czochralski substrate not precisely known
 - -> additional source of uncertainties
- Comparison to data helps to confirm assumed resistivity
- Reconstruction and analysis of test-beam data currently on-going





Summary and outlook



- Advanced simulation techniques required for complex sensor designs
- Simulations using electrostatic 3D TCAD and a MC framework allow for an accurate sensor modelling and high statistics
- Uncertainties are dominated by doping profiles of the pixel implants
- Good agreement over a wide parameter range
- Comparison between data and simulation for advanced starting materials on-going







BACK - UP



Hit detection efficiency



- Good agreement at low/intermediate detection thresholds
- Simulation with linear field clearly overestimates efficiency





Comparison with data





Test-Beam set-up at DESY

- Beam: 5.6 GeV electrons
- 6 MIMOSA-26 + 1 Timepix3 sensor planes are used to form reference track
- Timepix3 sensor provides reference time-stamp (~ 1.1 ns)



Simulation set-up

- Simulated beam particles : 5.6 GeV electrons
- Monte Carlo truth information used as spatial and timing reference (smeared with telescope resolution)



- Detector channel consists of 8 subpixels (diode + analogue front-end)
- Channel pitch: 300 μm x 30 μm (16x128 channels)
- Collection electrode pitch: 37.5 μm x 30.0 μm

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 Discriminator output of sub-pixels is combined in logic OR for ToT and ToA measurements (one ToT and ToA per channel)



- Save space for digital circuitry while maintaining small capacitance and fast charge collection
- 8-bit ToA (10 ns ToA bins) + 5-bit ToT (programmable from 0.6 4.8 μs) (combined ToA/ToT for every 8 sub-pixels in 300μm dimension)

Time resolution

- Steeper slope for high signal heights (time-walk)
- Can be corrected offline by using charge information
- Time-of-Arrival (threshold crossing)/Timeover-Threshold (clock cycles above threshold) used to measure time/charge

Challenges in data

- Non-linear relationship between ToT and charge in physical units
 - Limited range of test-pulse signal
- Restricted charge measurement range (up to ToT 30)
- 100 MHz ToA clock limits time measurements
- Limited statistics: full matrix is used for obtaining correction factors



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Seed pixel ToT

30

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Time resolution

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 Simulation contains no front-end contribution (no time jitter) but only ideal sensor timing -> helpful to understand impact of sensor design on timing

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Time resolution



- Reconstruction challenges in data can be largely overcome in simulation, which helps to study their impact on the final result
- Timing in data is dominated by front-end effects
- Direct comparison to simulation not possible

